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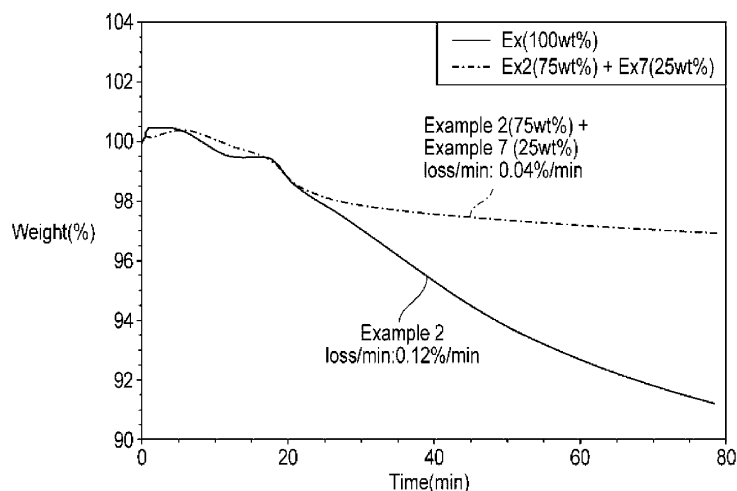


FIG. 1: Comparison of the isothermal baking behavior of Example 2 vs.
a mixture of Example 2 (75wt%) and Example 7 (25wt%).
Curing: +3wt% IrgacureOXE02 & 3wt% Irgacure651, 5.5 J/cm² (at 365 nm) + 250 °C/2min.
TGA method: sample was heated from room temperature to 400 °C over a period of 20 min,
followed by holding the temperature at 400 °C for 60 min.

(57) Abstract: The present invention relates to a curable composition, preferably being a photo-curable composition, comprising at least a 1st monomer compound; a 2nd monomer compound; and a polymerization initiator.

[Continued on next page]

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